Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	9	("4372825" "4443304" "4534832" " 4772371").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 14:31
S2	86	("205"/83,96,.ccls. "204"/211.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (apparatus system chamber device machine tool) and shield	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 14:36
S3	5	("205"/83,96,.ccls. "204"/211.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (apparatus system chamber device machine tool) and shield and sparger	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 14:39
S4 ⁻	5	("205"/83,96,146.ccls. "204"/211. ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (apparatus system chamber device machine tool) and shield and sparger	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 14:39
S5		("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (apparatus system chamber device machine tool) and shield and sparger	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 14:42
S6	1	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and shield and sparger not S5	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR .	ON	2006/04/25 14:44
S7	83111	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and shield and sparger plenum	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 14:44
S8	122	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and shield and plenum	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 14:45

S9	23	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and shield and plenum near10 (electrolyte solution)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 14:49
S10	259	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and current near7 shield	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 14:50
S11	58	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and current near7 shield and channel	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 14:58
S12	28	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and current with shield and channel not \$11	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 14:56
S13	8	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and current near10 shield and egress	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 15:07
S14	204	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and technic	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 15:08
S15	3	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and technic and mp	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 15:07
S16	204	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and "Technic"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 15:08

S17		("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and "Technic" near inc	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 15:09
S18	39	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and "Technic" near inc and vertical	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 15:10
S19	16	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and "Technic" near inc and vertical and shield	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 15:10
S20	18	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and "Technic" near inc and vertical and shield\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 15:20
S21	19	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and "Technic" near inc and shield\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 15:14
S22	1533	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and vertical and shield\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 15:21
S23	112	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and vertical near10 shield\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 16:52
S24	2	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and vertical near10 shield\$3 and sparger	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 15:22

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S25	469	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and	US-PGPUB; USPAT; USOCR; EPO; JPO;	OR	ON	2006/04/25 15:33
S26	2	vertical near10 channel ("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic	DERWENT; IBM_TDB US-PGPUB; USPAT;	OR	ON	2006/04/25 15:34
		electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and vertical near10 channel and sparger	USOCR; EPO; JPO; DERWENT; IBM_TDB			
S27	0	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and (lowerupper) near10 channel and sparger	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 15:35
S28	7	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and (lower upper) near10 channel and sparger	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 16:02
S29	21	("204"/230.2.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and shield	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 15:58
S30	424	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and ((inlet) near10 solution) same (series plurality)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 16:04
S31	151	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and ((inlet near10 solution) same (series plurality)) same bottom	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 16:12
S32	2	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and (inlet near10 (series plurality)) same bottom and sparger	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 16:13

S33	4	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and vertical near10 shield\$3 and ((inlet near10 solution) same (series plurality)) same bottom	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/26 11:03
S34	17	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and vertical near10 shield\$3 and ((inlet near10 solution)) same bottom	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 16:55
S35	18	(electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and vertical near10 shield\$3 and ((inlet near10 solution)) same bottom	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 16:54
S36	115	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and shield\$3 and ((inlet near10 solution)) same bottom	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 16:57
S37	14	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and shield\$3 with current and ((inlet near10 solution)) same bottom	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 17:28
S38	7	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and (thief or thieves) with current and ((inlet near10 solution)) same bottom	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/26 11:01
S39	12	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and (thief or thieves) with current and ((inlet near10 solution))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 17:02
S40	103	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and (thief or thieves) with current	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/26 11:46

S41	174	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and shield\$3 with current and strip	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/25 17:28
S42	12	("204"/232.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and ((inlet near10 solution)) same bottom	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/26 11:04
S43	3	("204"/245.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and ((inlet near10 solution)) same bottom	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/26 11:04
S44	1	("204"/245.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and ((inlet near10 solution)) same (series plurality)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/26 11:05
S45	7	("204"/255.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and ((inlet near10 solution)) same (series plurality)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/26 11:06
S46	9	("204"/257.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and ((inlet near10 solution)) same (series plurality)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/26 11:07
S47	65	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and (thief or thieves) with current and vertical\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/26 11:20
S48	81	(electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and (thief or thieves) with current and vertical\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/26 11:20

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S49	23	(electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and ((thief or thieves) with current) same vertical\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/26 11:20
S50	16	("3437578" "3652442" "4102756" "4678545" "4828653" "5135636" "5516412" "5620581" "6001235" "6027631" "6071388" "6074544" "6077405" "6113759" "6391168").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2006/04/26 11:22
S51	16	("3437578" "3652442" "4102756" "4678545" "4828653" "5135636" "5516412" "5620581" "6001235" "6027631" "6071388" "6074544" "6077405" "6113759" "6391168").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2006/04/26 11:28
S52	4	("3880725" "4534832" "4879007" "5401370").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2006/04/26 11:34
S53	9	("2859166" "3090823" "3821097" "3862891" "4113586" "4879007").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2006/04/26 11:34
S54	4	("3880725" "4534832" "4879007" "5401370").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2006/04/26 11:45
S55	32	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and (thief or thieves) with current and distance near10 (cathode substrate workpiece)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/04/26 11:47